

Heat Resistance Comparison (Reference Value)

Cepla SA101 Other Polyimide

- Extend work life in applications in high temperature environments
- Improve the specifications of equipment mounted on ovens, etc.

Heat resistance	Cepla SA101	Other
Thermal deformation temperature (18.56kg/cm ²)	470°C	360°C
Continuous operating temperature (Actual value)	300°C ~ 350°C	250°C
Linear expansion coefficient (ppm/°C)	35(25~450°C)	54(23~300°C)

Comparison of mechanical strength (reference value) Cepla SA101 Other Polyimide

- High mechanical strength
- Weight reduction during wear resistance

Mechanical strength	Cepla SA101	Other
Tensile strength(260°C)	47	37
Bending strength(260°C)	51	45
Bend modulus(260°C)	3.6	1.4
Rockwell Hardness	115	45~58

Characteristic comparison (reference value)

Cepla SA101 Other Polyimide

Semiconductor manufacturing equipment applications Plasma etching equipment, annealing equipment parts

Plasma immunity, low outgassing, low water absorption

	Cepla SA101	Other Pi
O ₂ Plasma immunity (etching speed) $\mu\text{g}/\text{cm}^2 \cdot \text{h}$	6.6	9.2
Gas emission characteristics in vacuum ($\text{Torr} \cdot \text{l}/\text{sec}/\text{cm}^2$)	5.5×10^{-4} (Measuring temperature 200°C)	2.0×10^{-3} (Measuring temperature 200°C)
Water absorption% (23°Cx 24h)	0.03	0.24